

Expecting the unknown...

A preliminary characterization of 3D silicon sensors by means of IV-CV measurements



CERN Internship: April 2015

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SSD/ PH-DT-DD

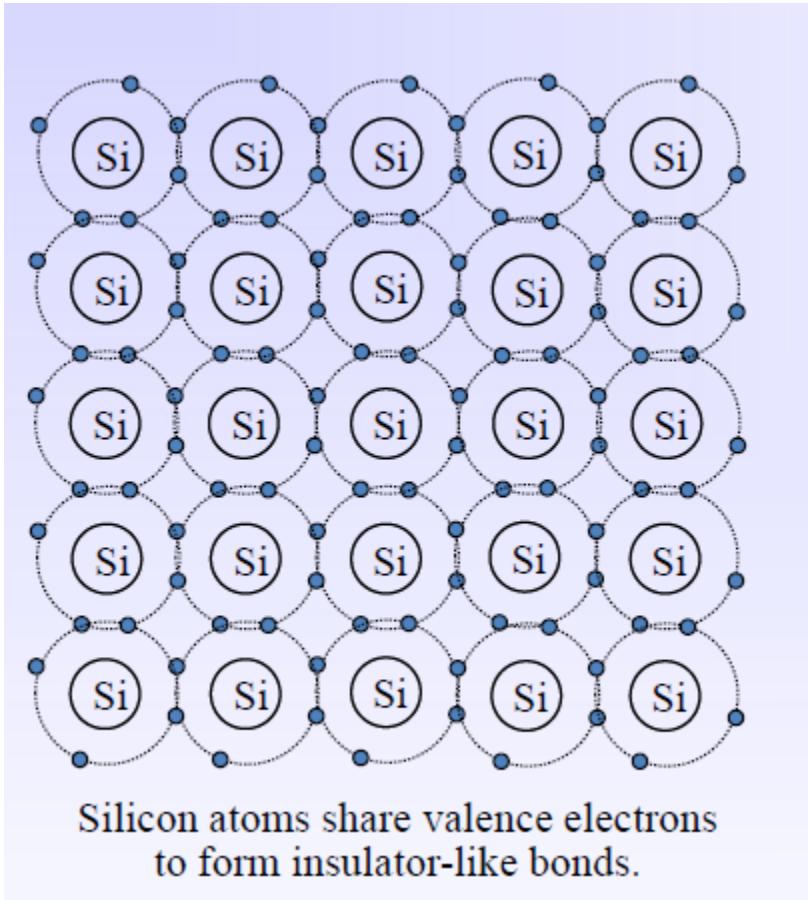


Outline



- **Silicon sensors**– The physics behind it
- **IV and CV** – The theoretical, ideal curve
- **My measurements** – The Setup
- **My results** – The experimental reality
- **Review on the internship** – What's left to say

The chemistry behind a semiconductor... Silicon sensors

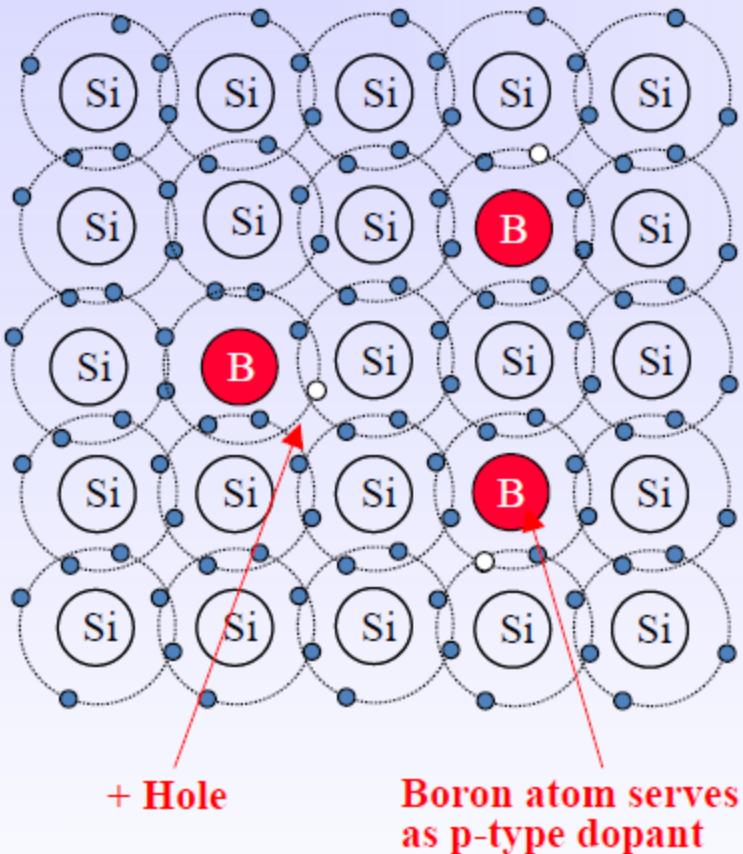


	II	III	IV	V	VI
2	9,0 Be 4	10,8 B 5	12,0 C 6	14,0 N 7	16,0 O 8
3	24,3 Mg 12	27,0 Al 13	28,1 Si 14	31,0 P 15	32,1 S 16
4	40,1 Ca 20	69,7 Ga 31	72,6 Ge 32	74,9 As 33	79,0 Se 34
5	87,6 Sr 38	114,8 In 49	118,7 Sn 50	121,8 Sb 51	127,6 Te 52
6	137,3 Ba 56	204,4 Tl 81	207,2 Pb 82	209,0 Bi 83	209 Po 84

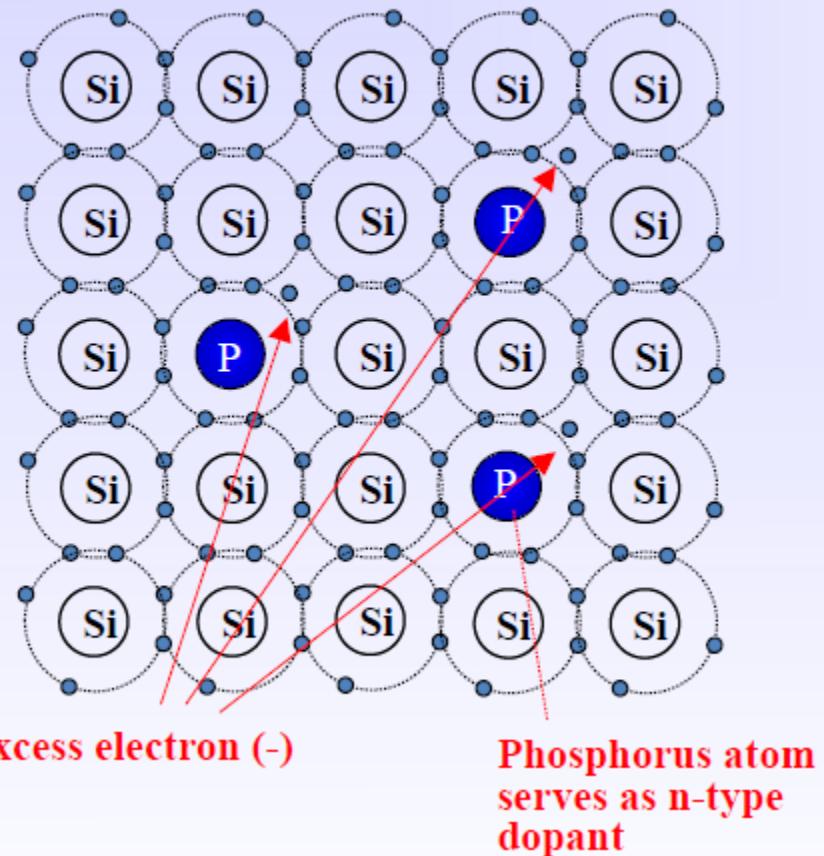
The chemistry behind a semiconductor... Silicon sensors



Acceptor atoms provide a deficiency of electrons to form p-type silicon.



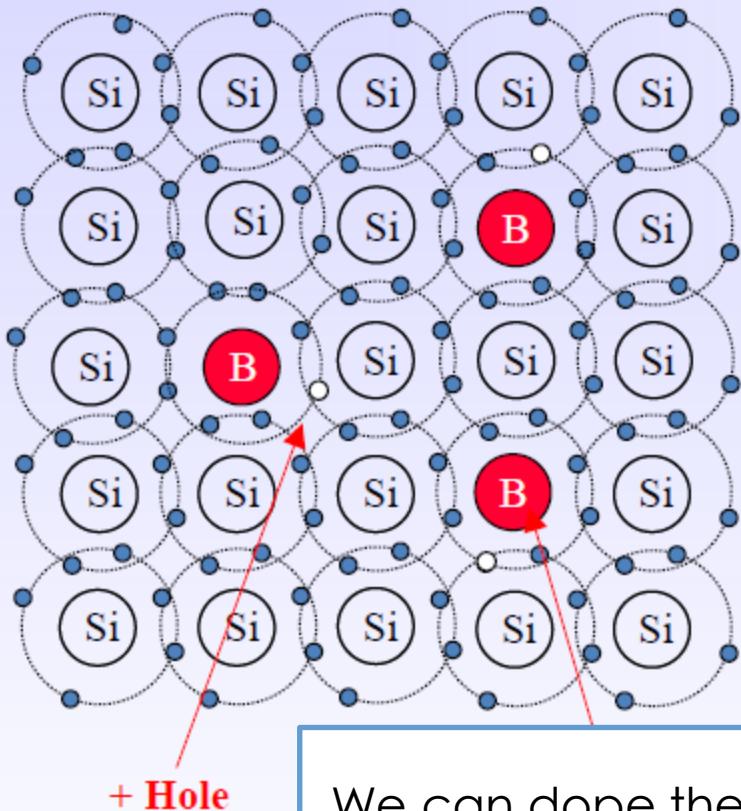
Donor atoms provide excess electrons to form n-type silicon.



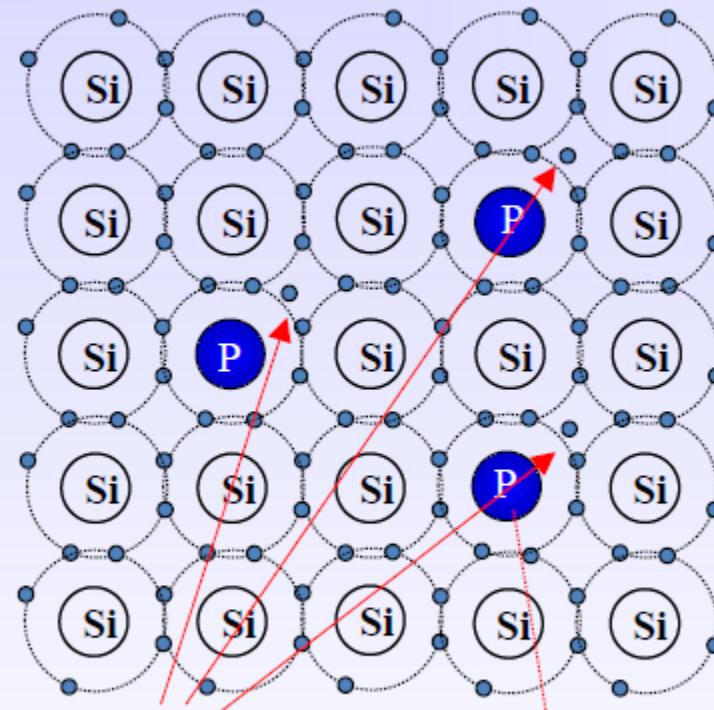
The chemistry behind a semiconductor... Silicon sensors



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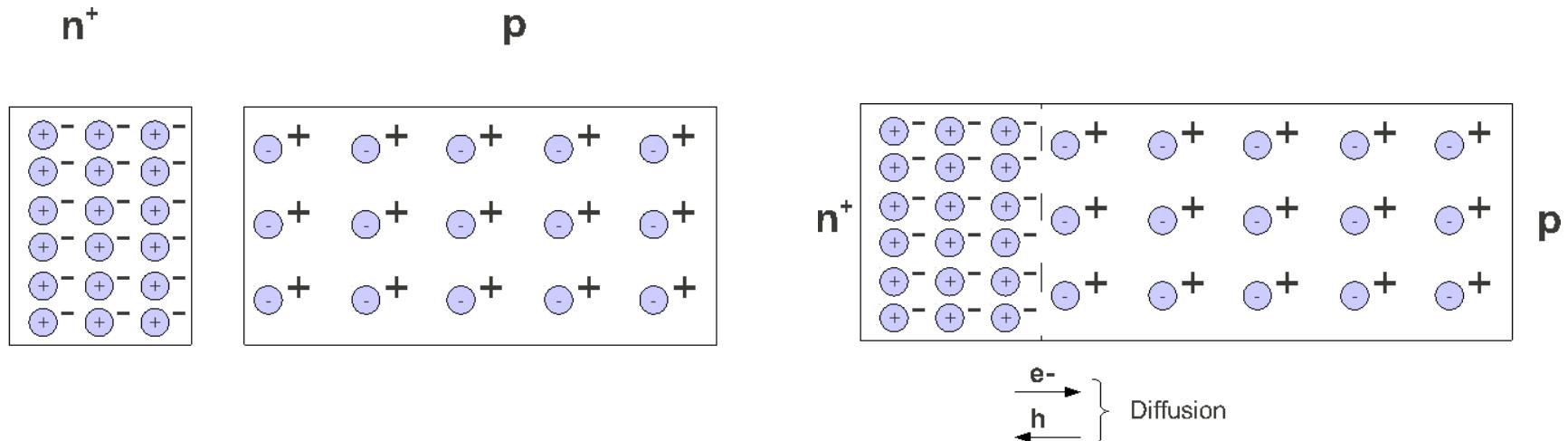
Donor atoms provide excess electrons to form n-type silicon.



We can dope the Si negatively or quasi positively.

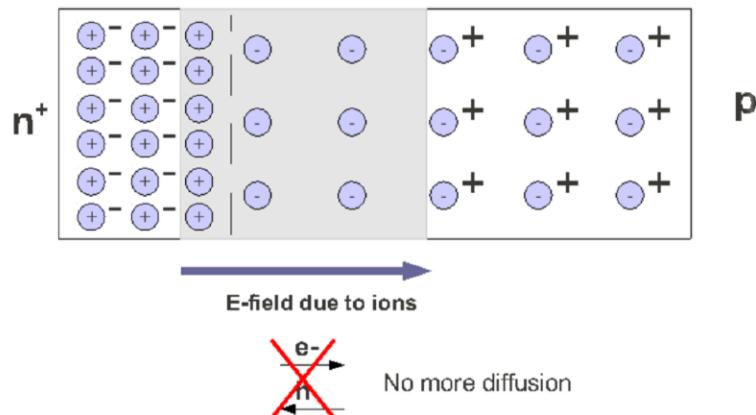
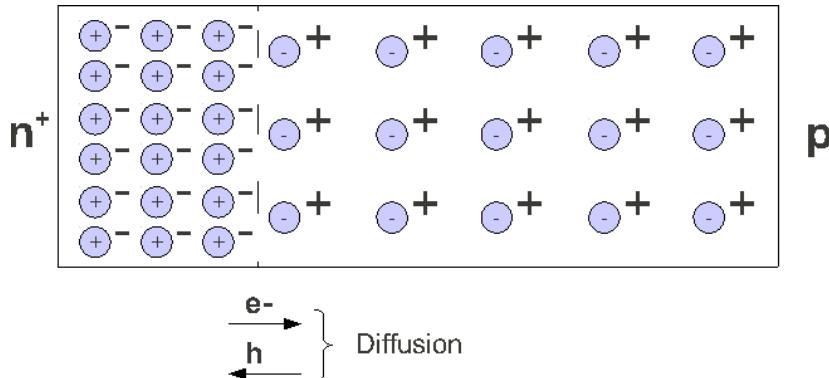
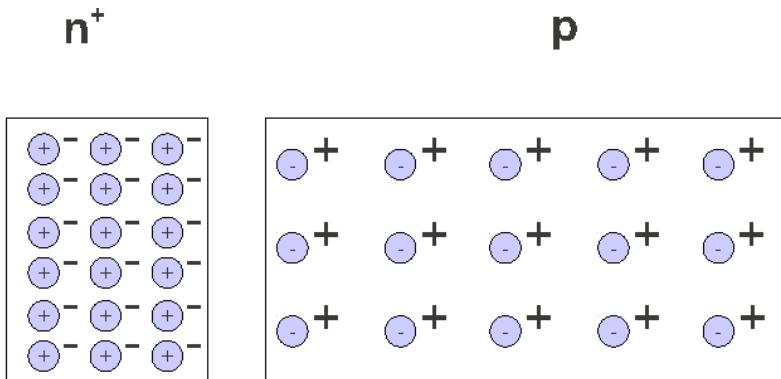
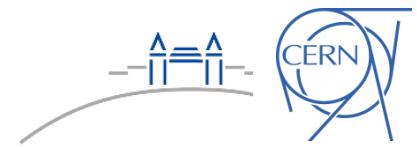
phorus atom
es as n-type
nt

The 2D physics behind a semiconductor... Silicon sensors



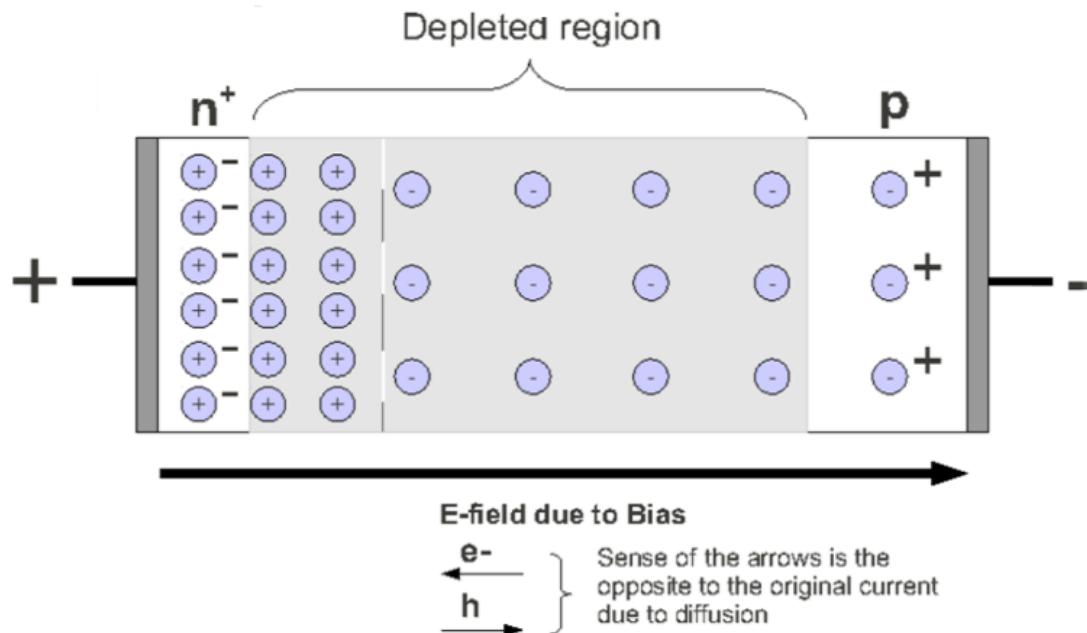
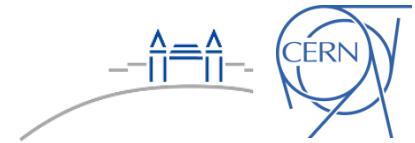
The two doped materials diffuse and the electrons fill the free holes.

The 2D physics behind a semiconductor... Silicon sensors



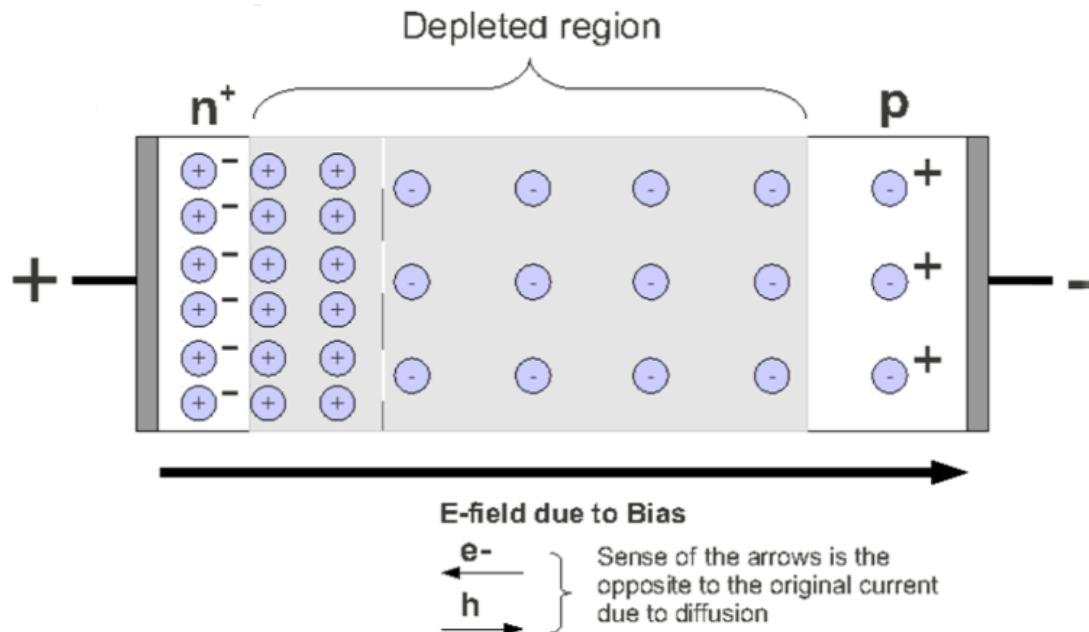
The diffusion has created an E-field, therefore the electron movement is stopped and the forces equalise each other.

The 2D physics behind a semiconductor... Silicon sensors



By applying a voltage we can increase the E-field and thus increase the width of the depletion to a fixed maximum.

The 2D physics behind a semiconductor... Silicon sensors

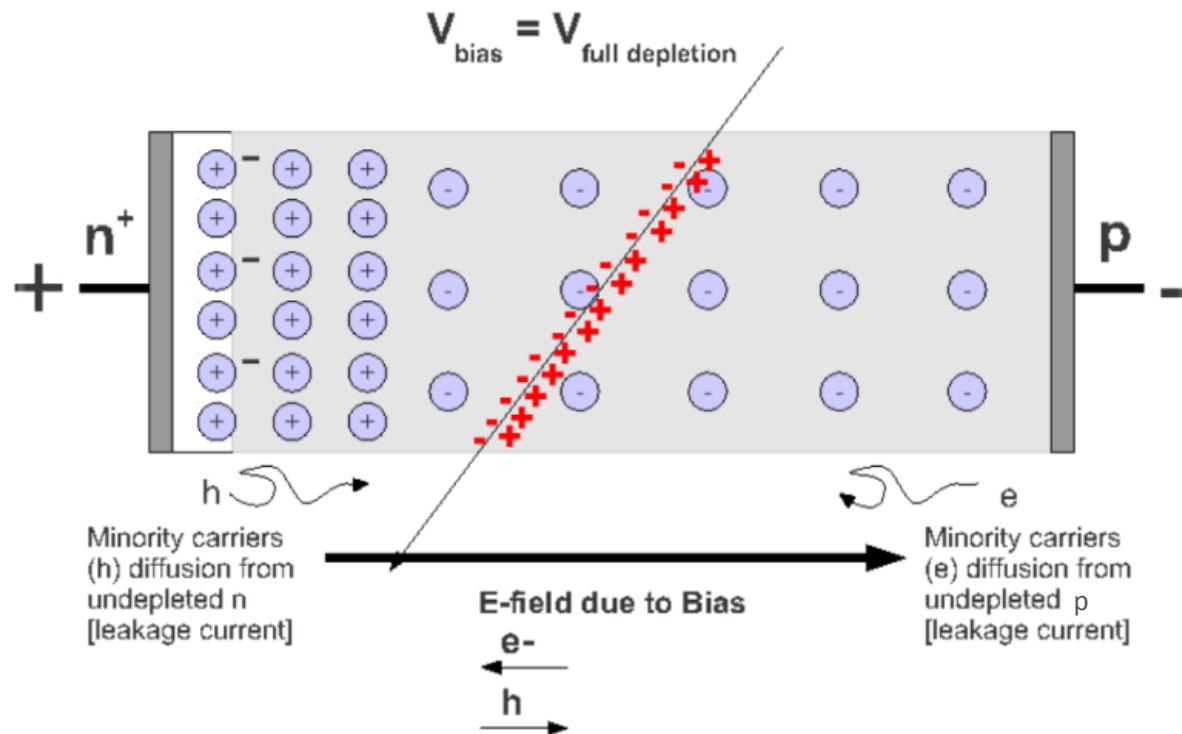
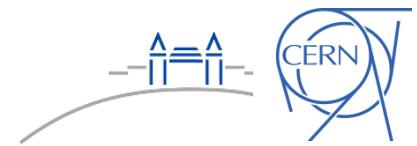


By applying a voltage we can increase the E-field and thus increase the width of the depletion to a fixed maximum.

1) The sensors can also be seen as a **capacitor** of variable thickness (as a function of V).

2) And a silicon sensor also is a diode.

The 2D physics behind a semiconductor... Silicon sensors

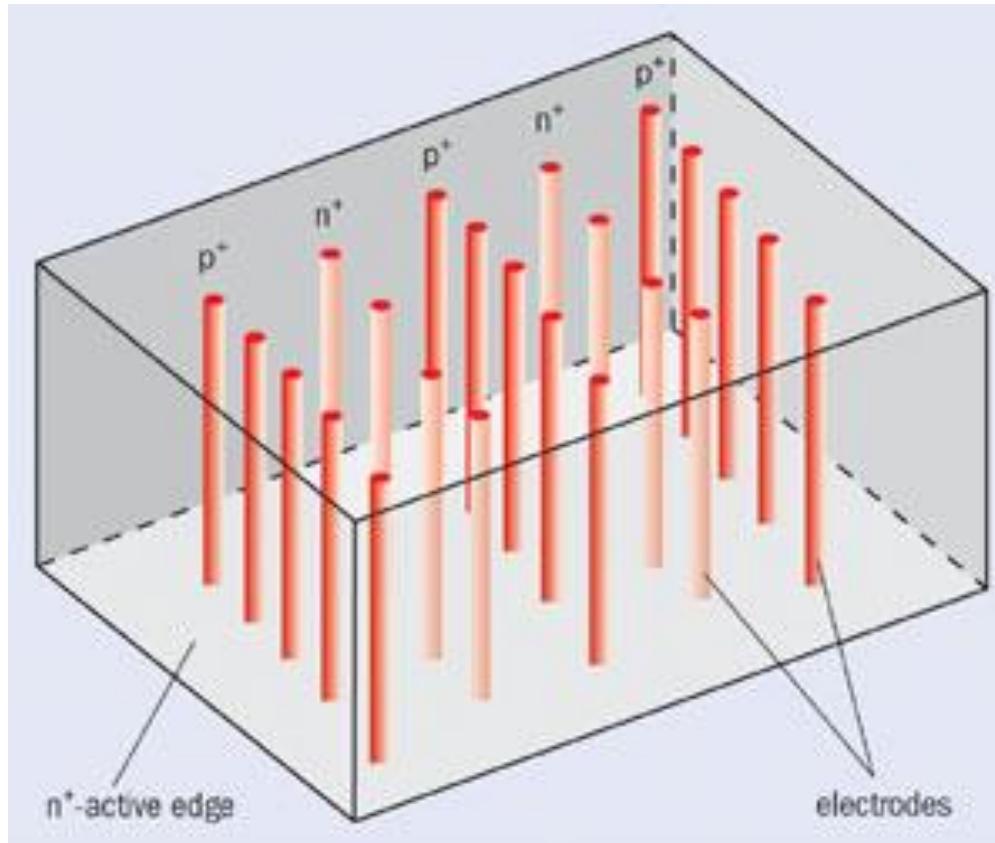


An ionising particle that passes the silicon sensor can be detected by the current it creates.

The aim is to keep the leakage current low.

The 3D visualisation

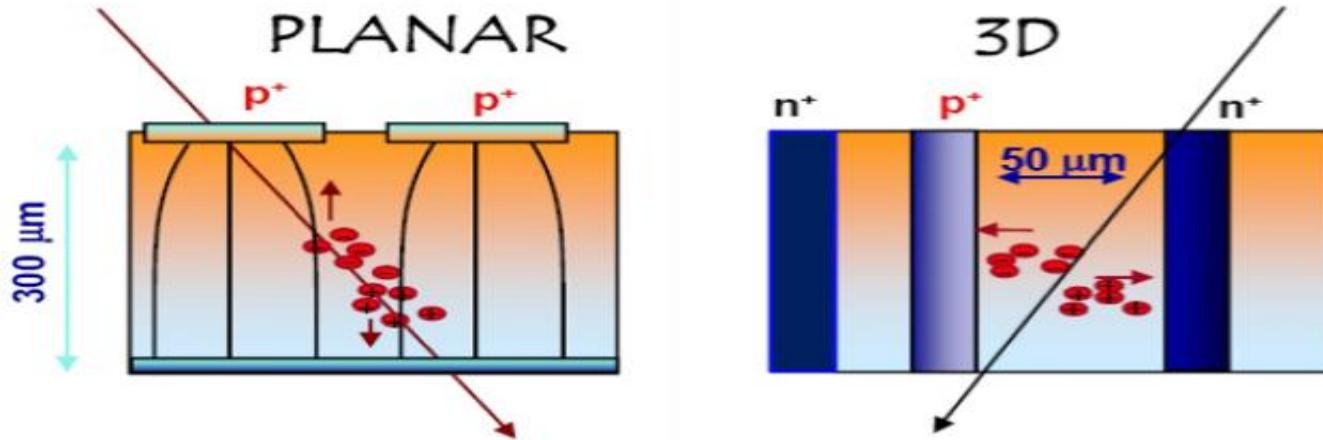
Silicon sensors



A 3D-sensor shows the same attributes as the 2D.

What dimension should it be?

Silicon sensors



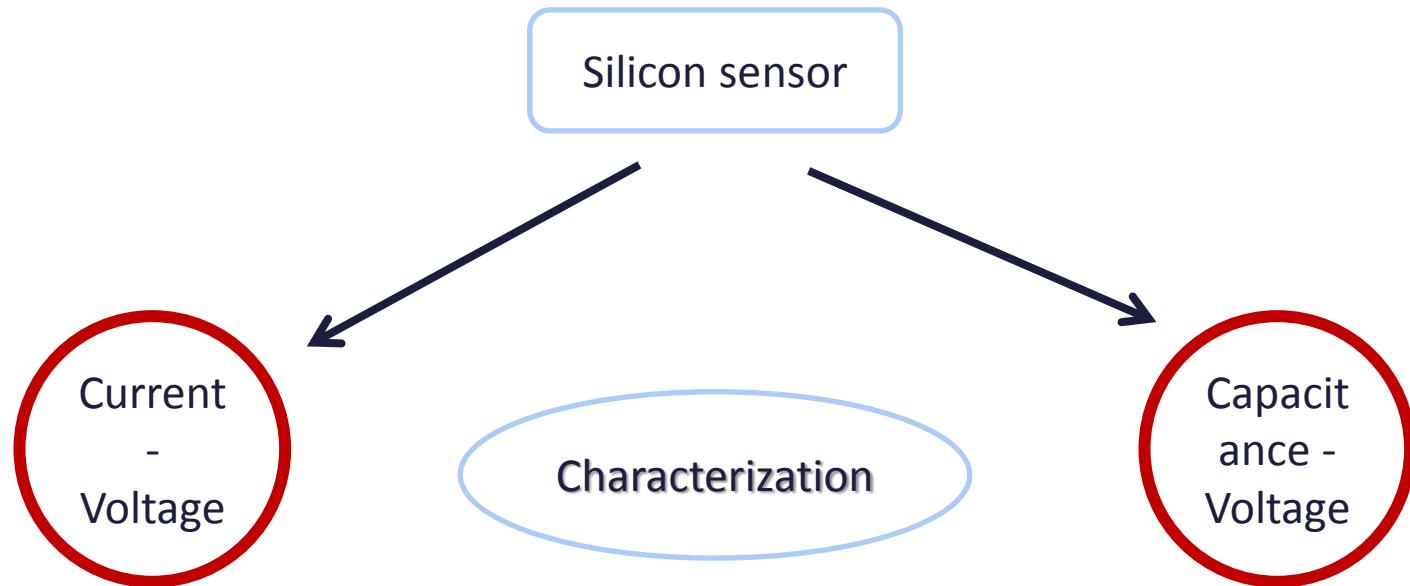
3Ds offer a faster charge collection
Smaller depletion voltage
& are radiation harder

BUT planar technology is the more consolidated

Both sensors show reasonable advantages.

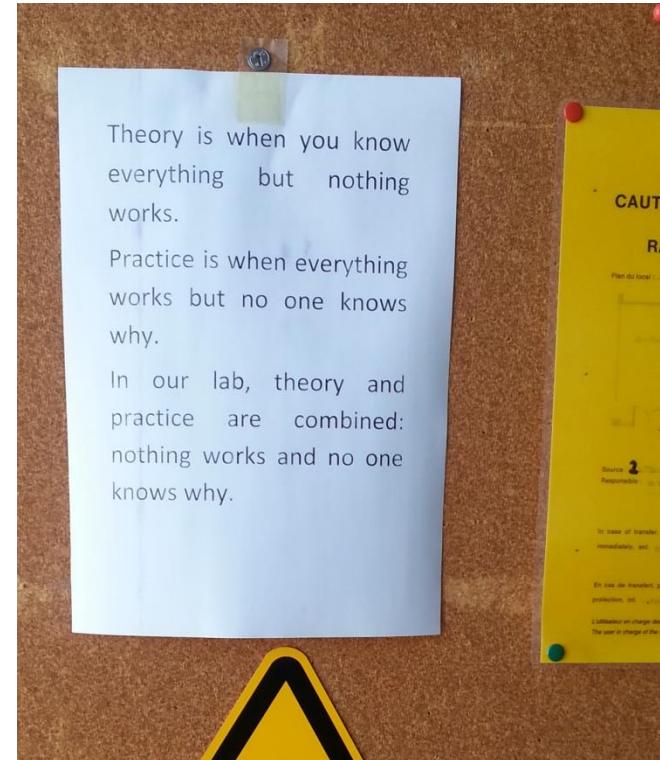
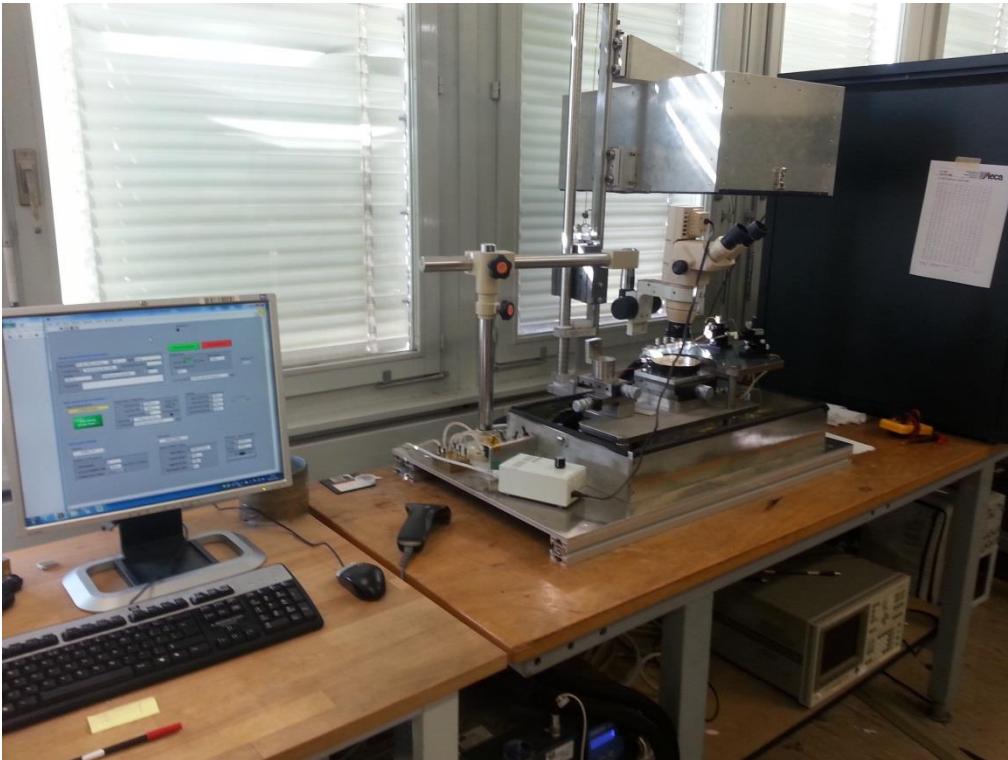
What are IV and CV measurements?

IV and CV theory



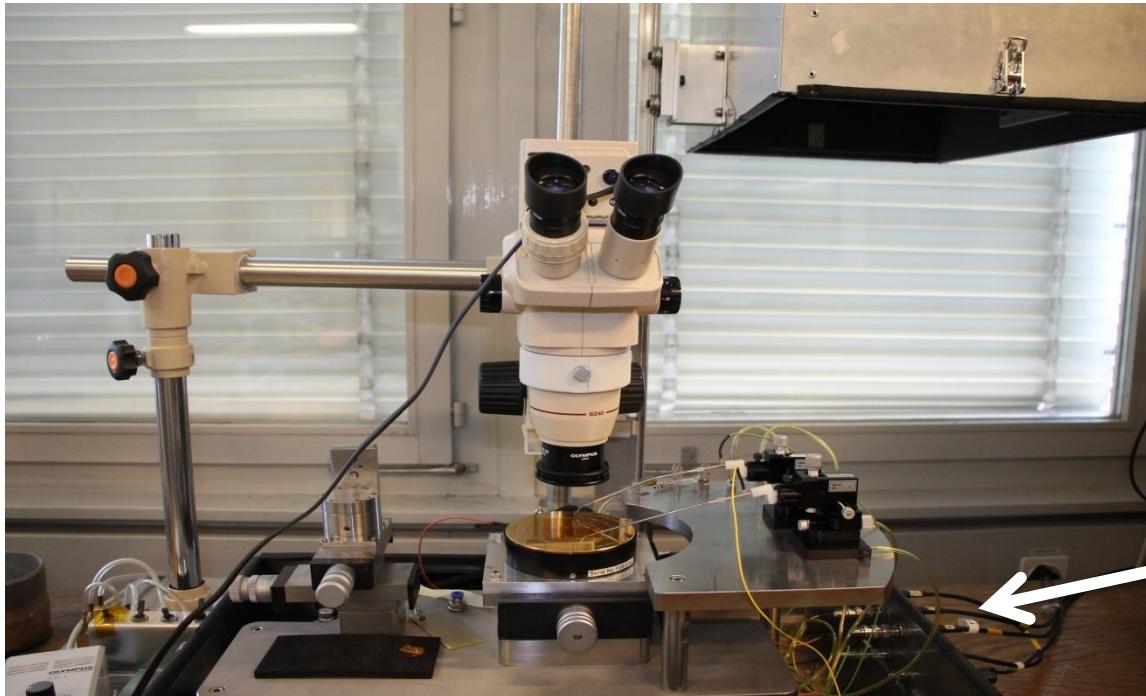
The lab: My place to be

Measurement-Set up



The lab: My place to be

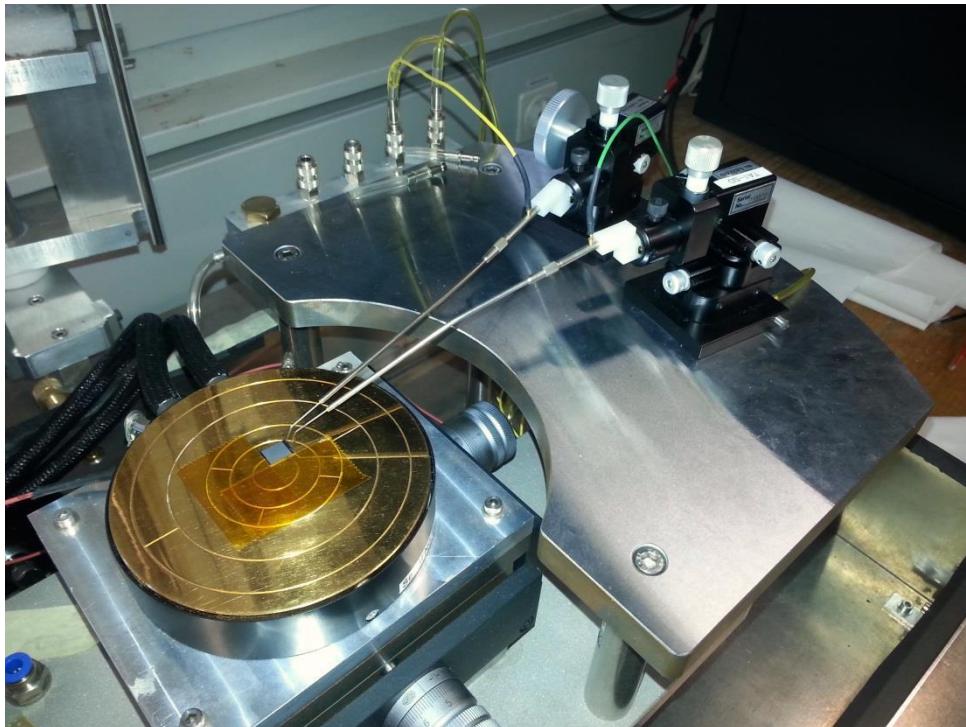
Measurement-Set up



We apply a voltage and measure I or C.

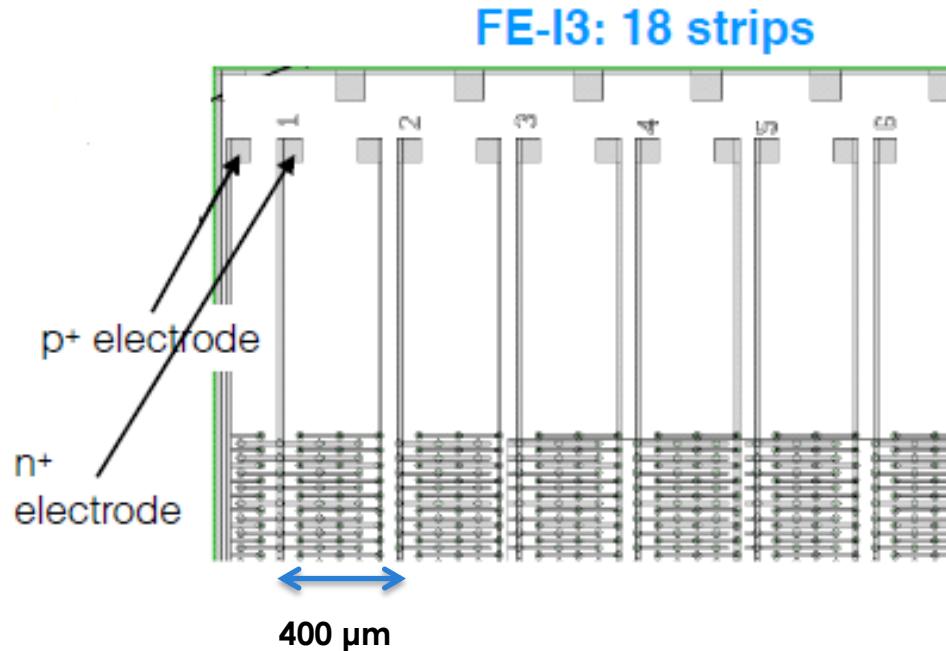
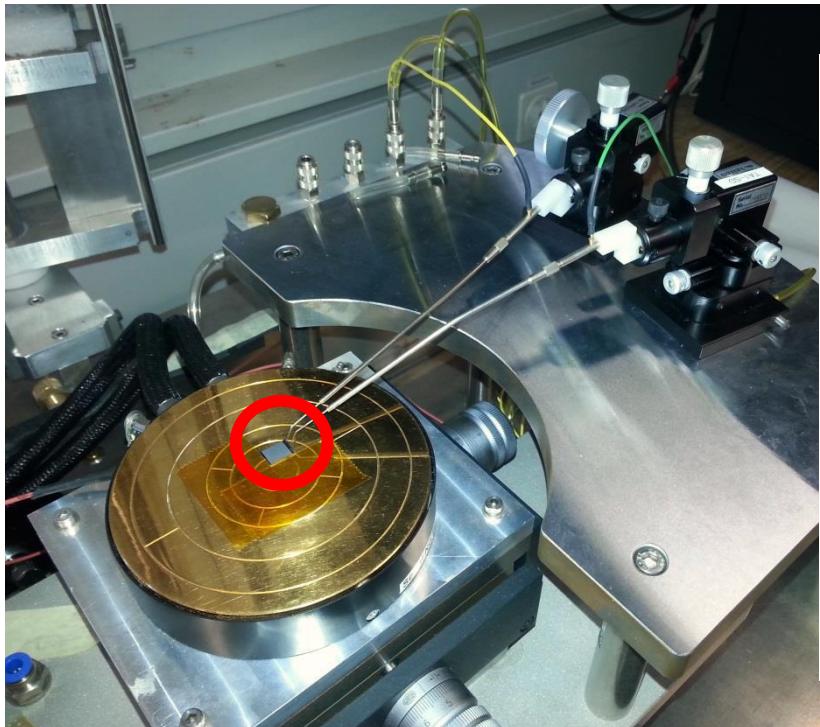
Close-up: Microscope & sensitivity needed

Measurement-Set up



Close-up: Microscope & sensitivity needed

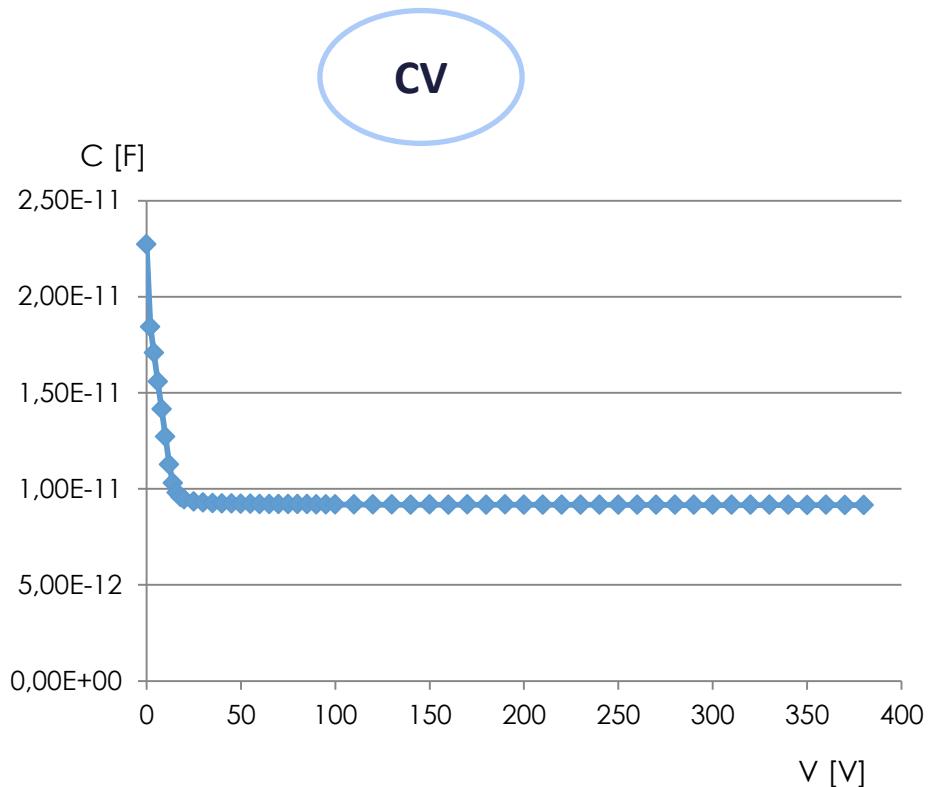
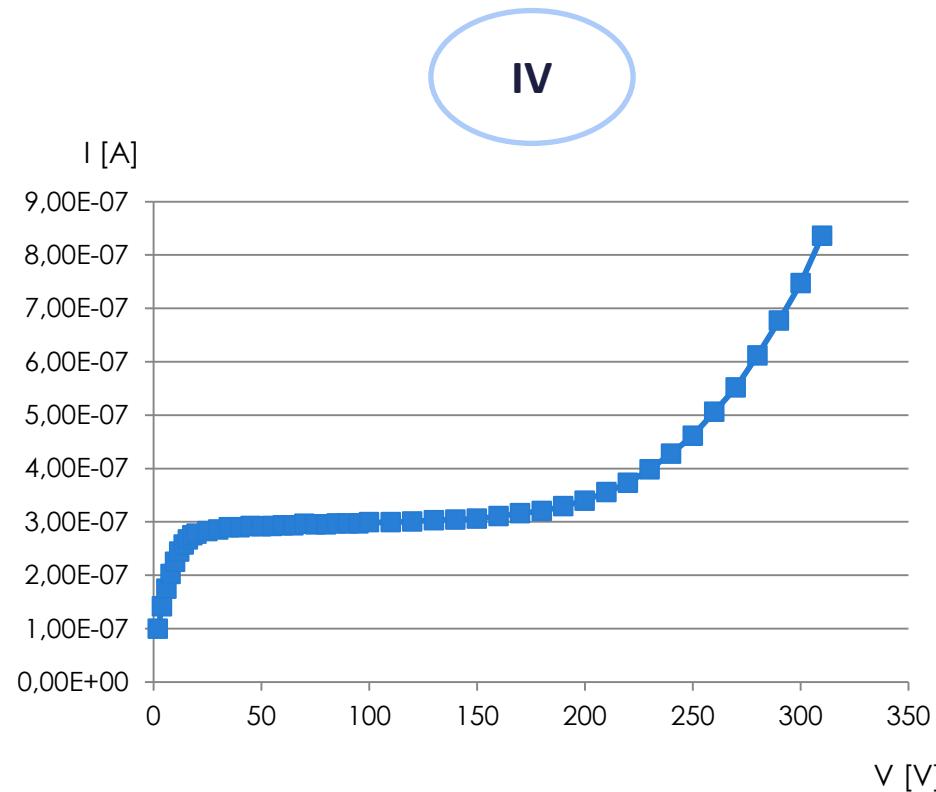
Measurement-Set up



Connecting both needles is precision work.

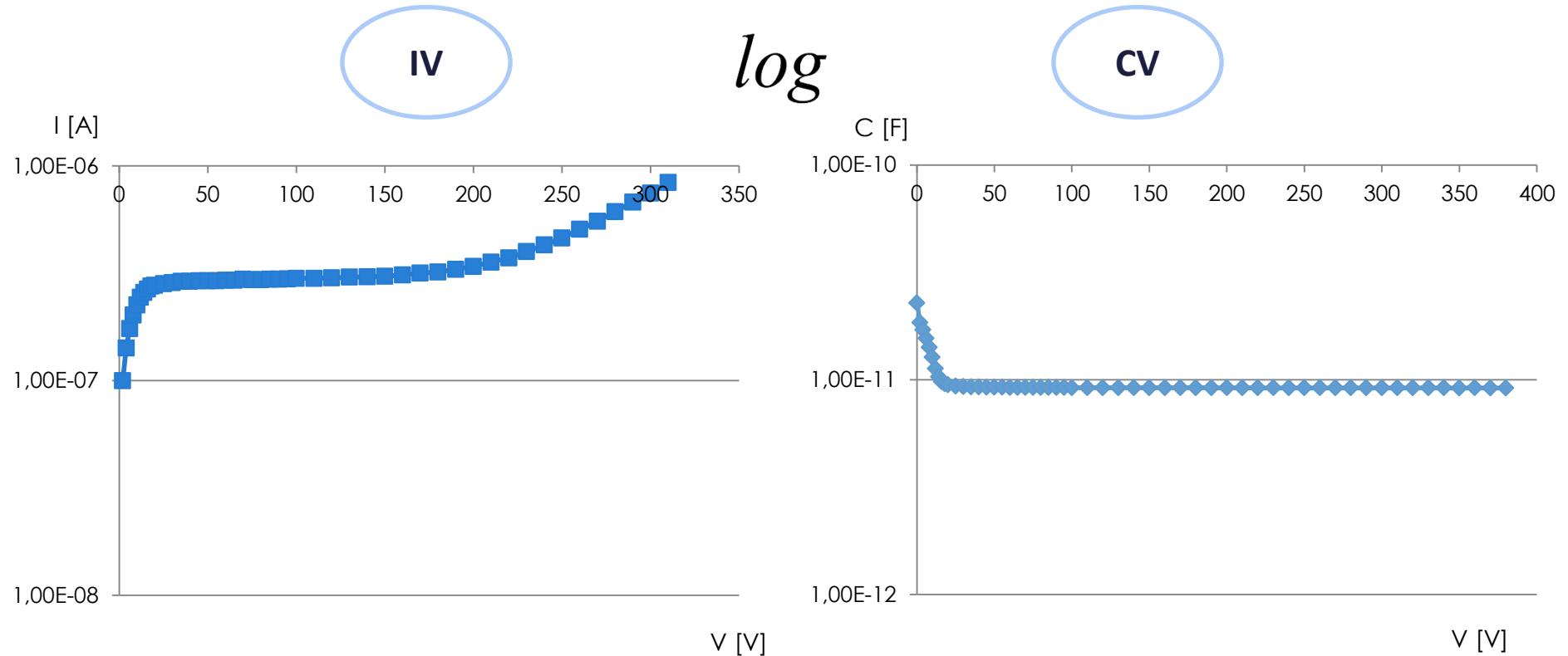
What are IV and CV measurements?

IV and CV theory



What are IV and CV measurements?

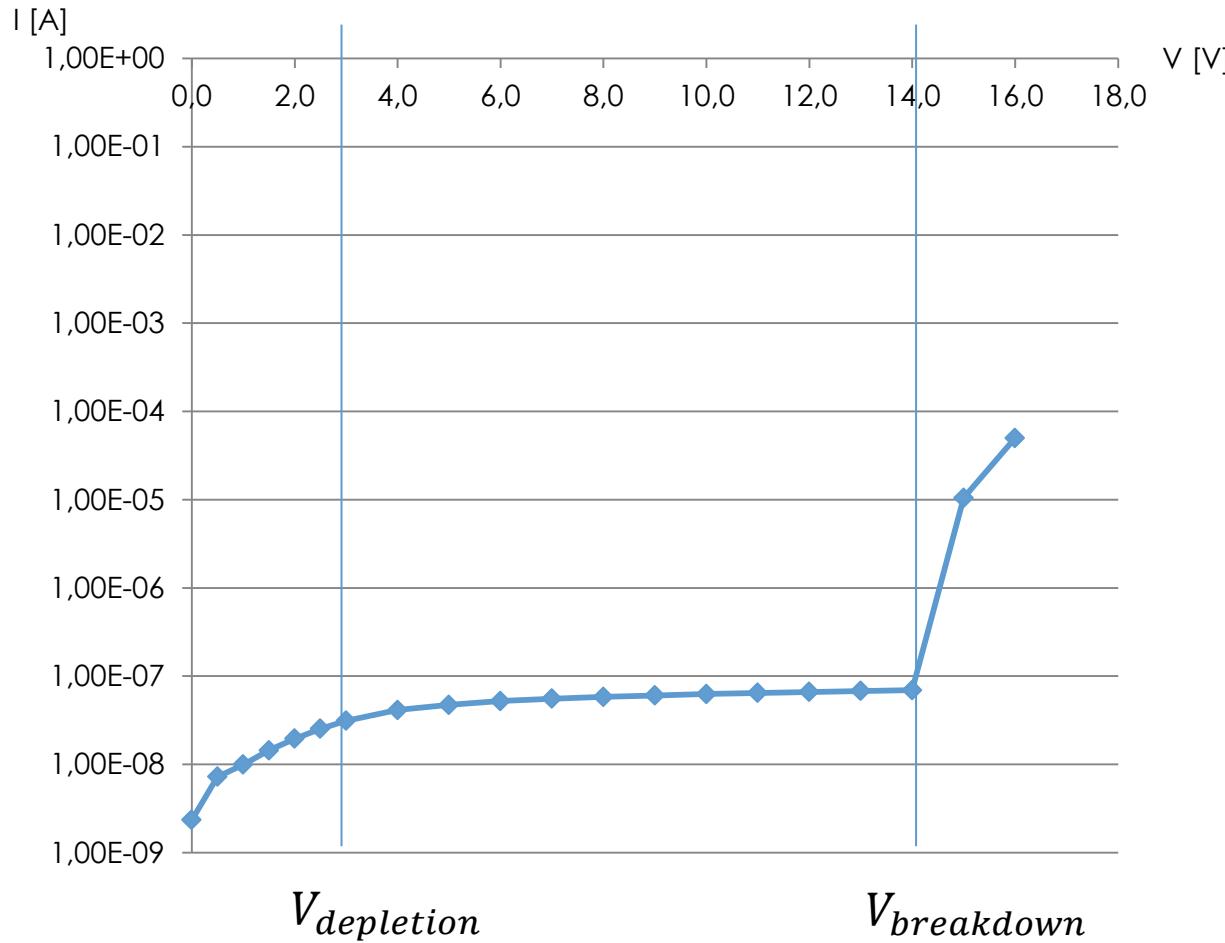
IV and CV theory



The depletion and breakdown voltages are important properties.

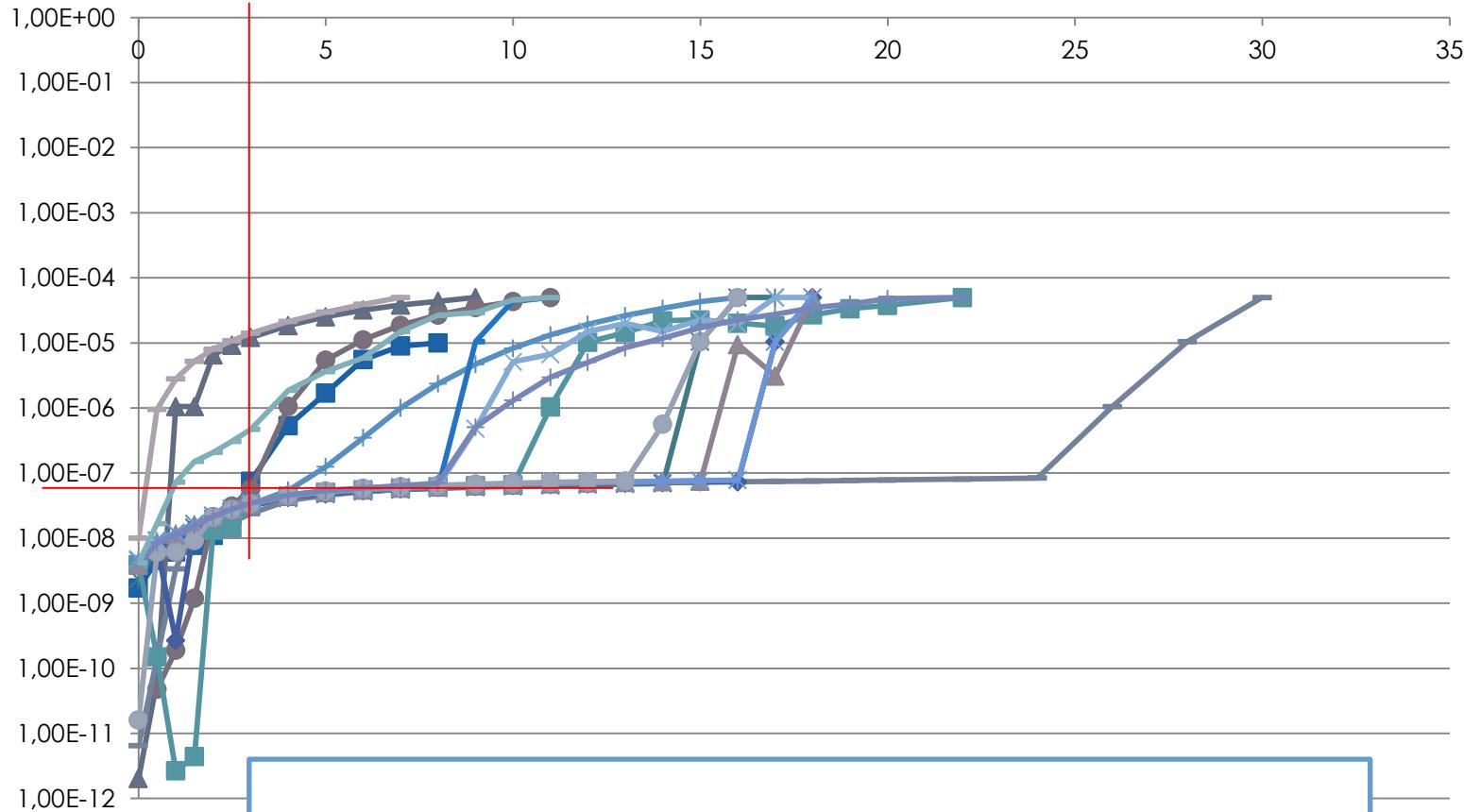
The 3D-IV result for one single strip

Measurement results



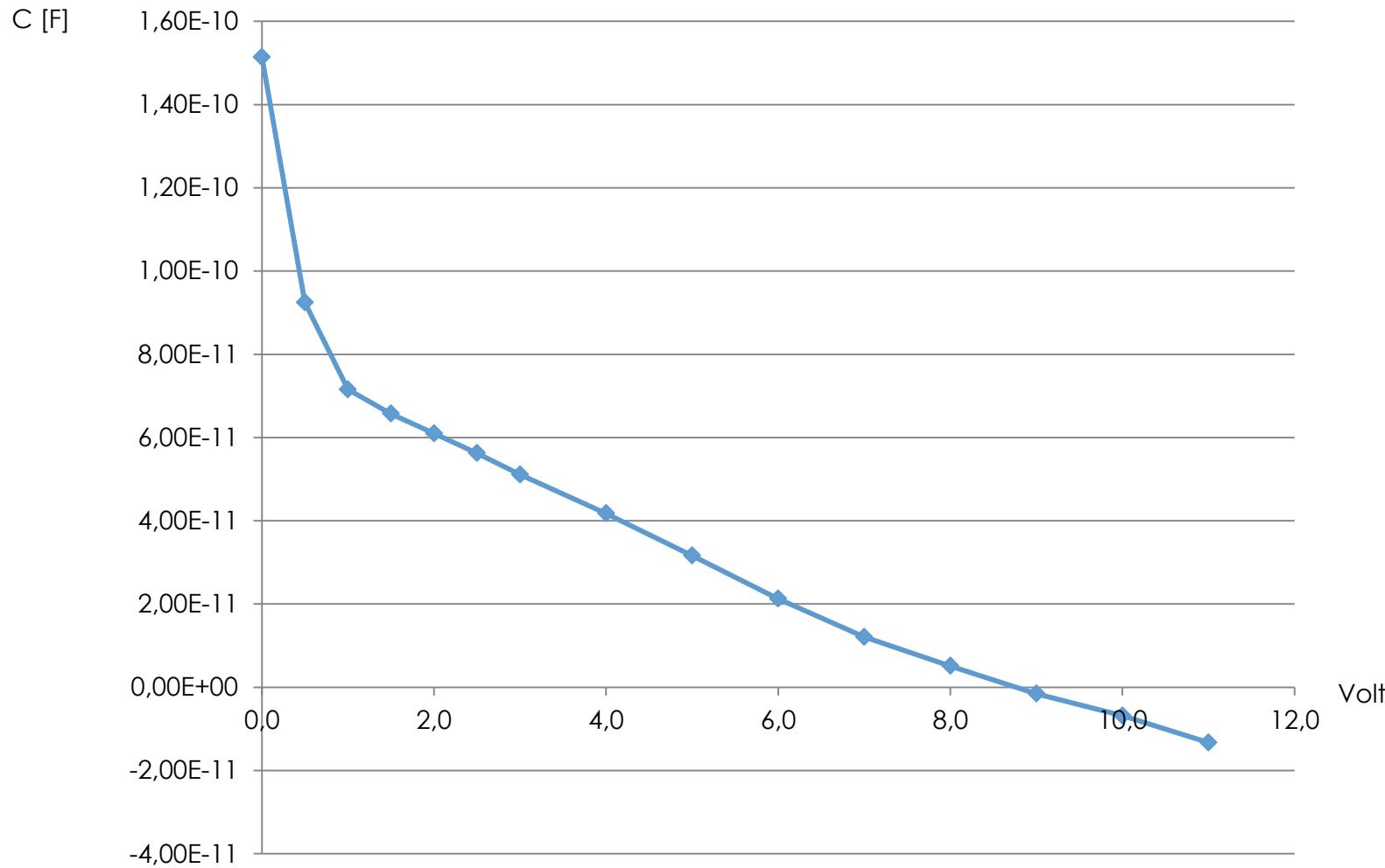
Overlapping strips create confusion

Measurement results



The 3D-CV result for one single strip

Measurement results



Introduction

Silicon sensors

Measurement Setup

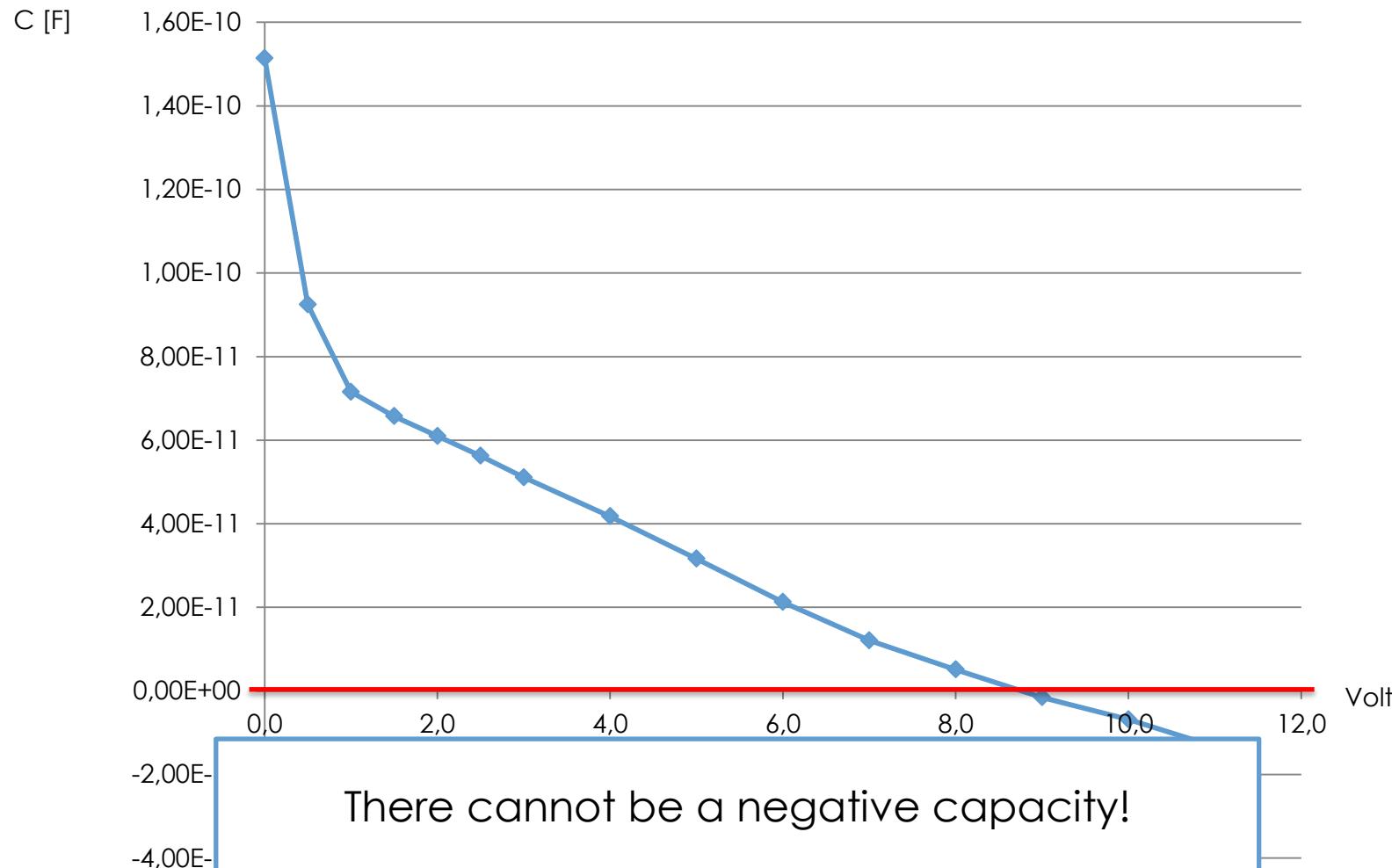
IV and CV theory

Measurement results

Review

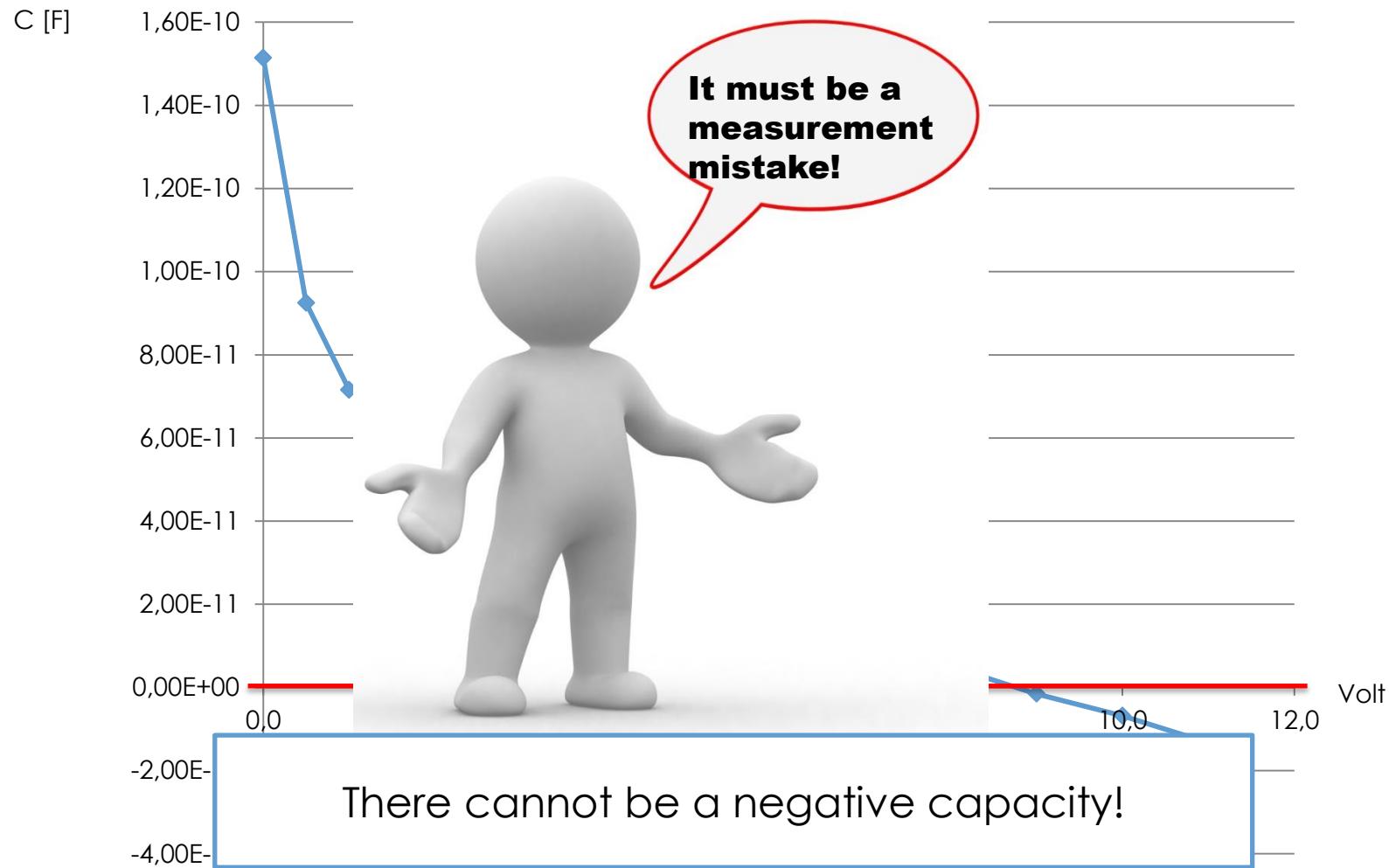
The 3D-CV result for one single strip

Measurement results



The 3D-CV result for one single strip

Measurement results



Capacitance and its use...

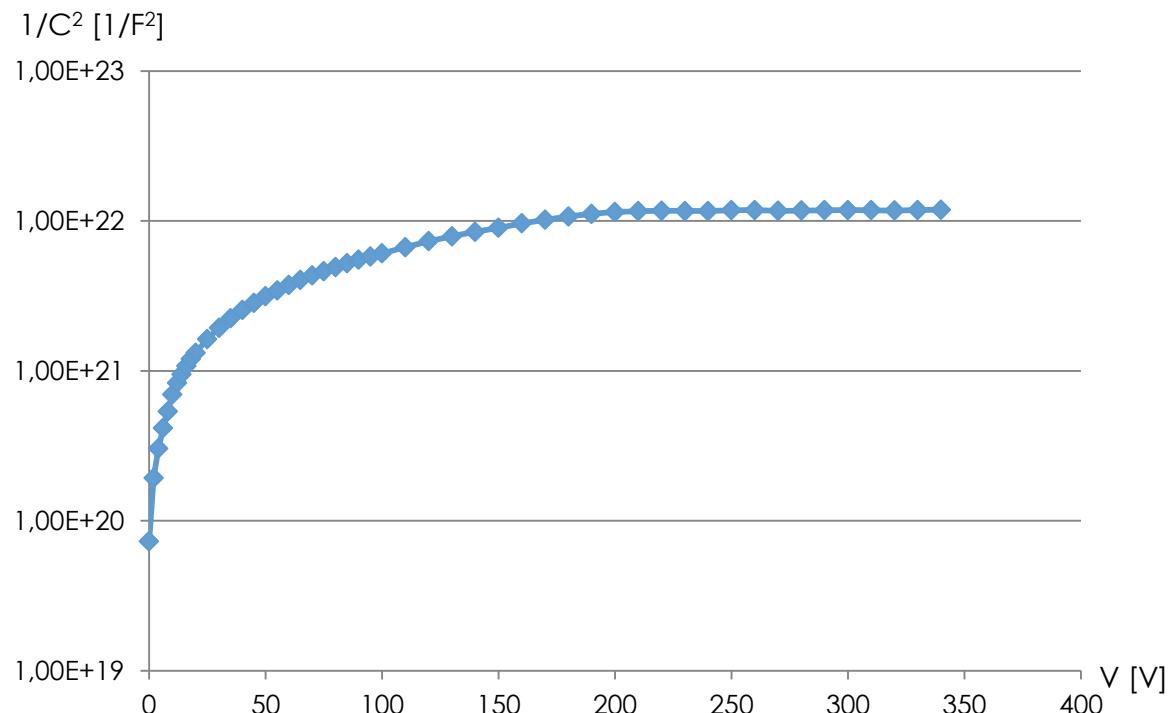
Measurement results



$$C = \frac{\epsilon_0 \epsilon_r S}{d}$$

$$w = \sqrt{\left(\frac{2\epsilon_0 \epsilon_{si}}{e|N_{eff}|} V\right)}$$

If $V = V_{depl}$ then $w = d$



Capacitance and its use...

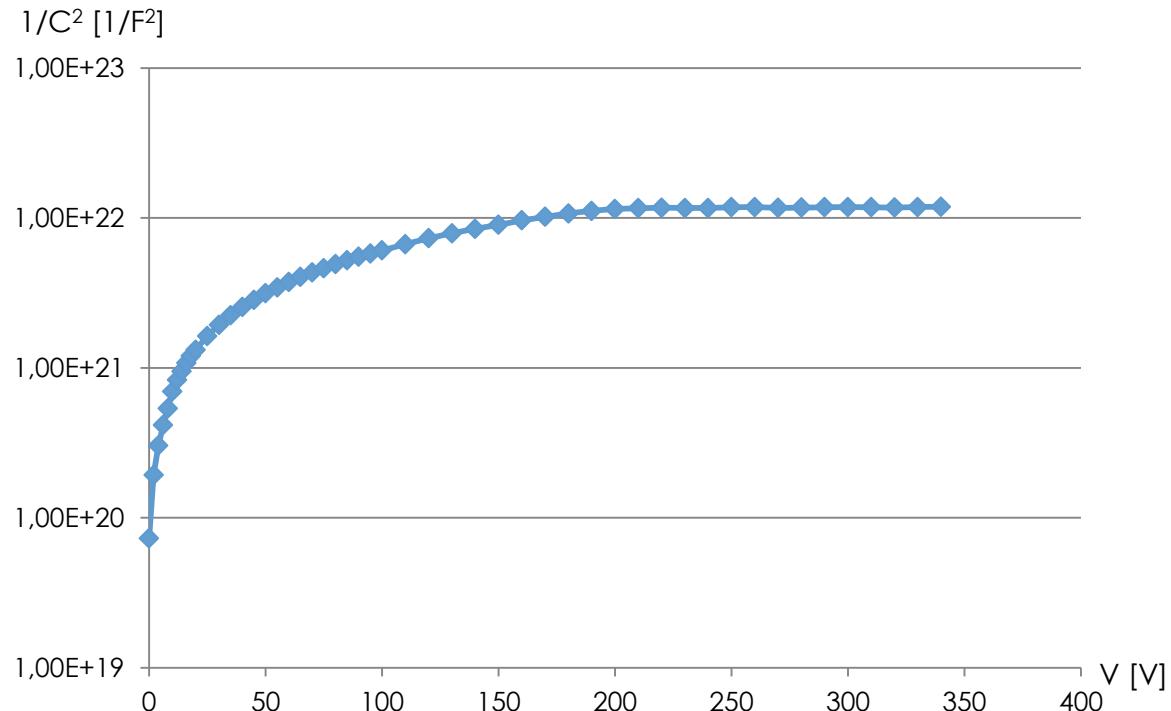
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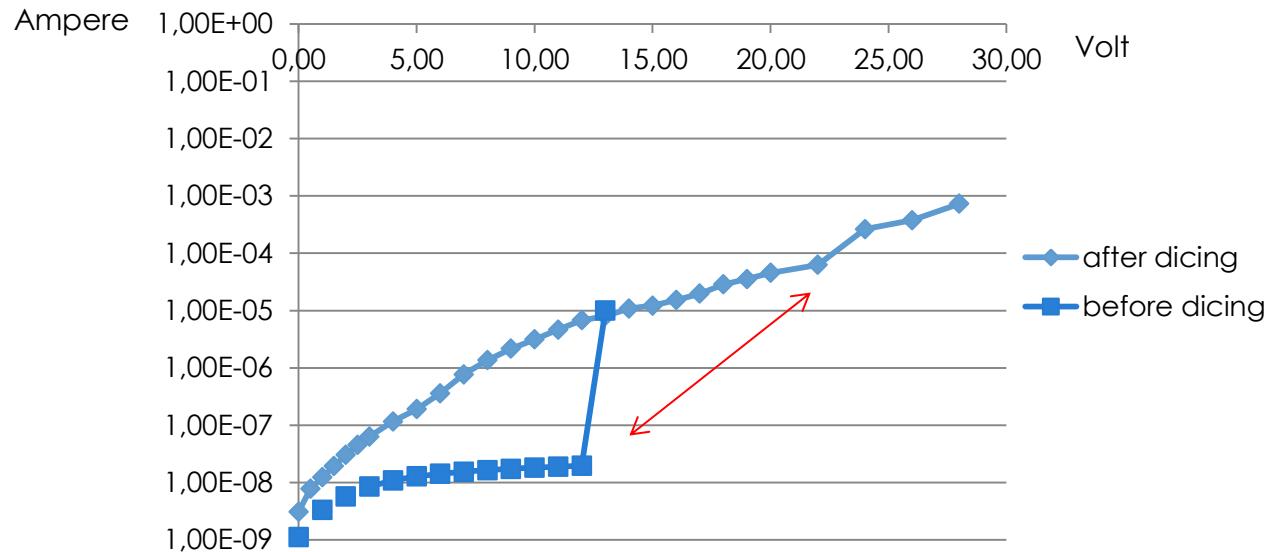
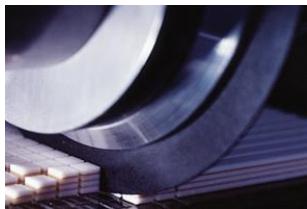
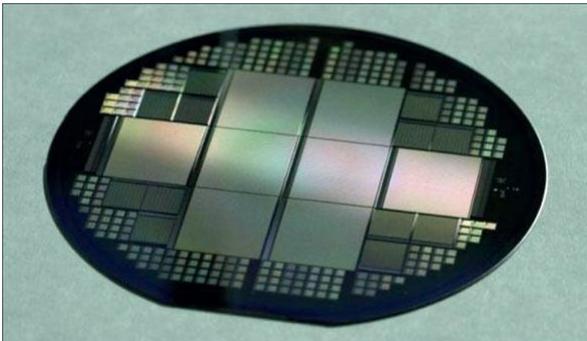
If $V = V_{depl}$ then $w = d$



N_{eff} (effective doping concentration) can be obtained by the depletion voltage.

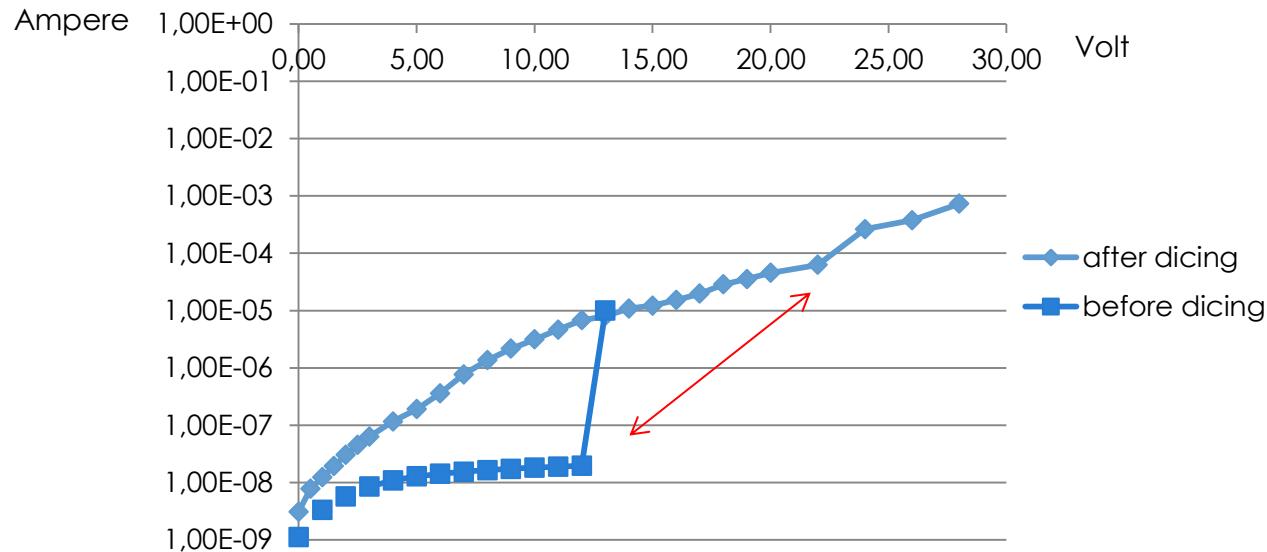
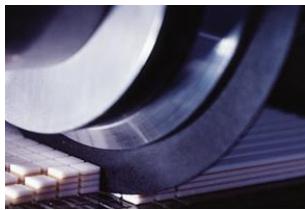
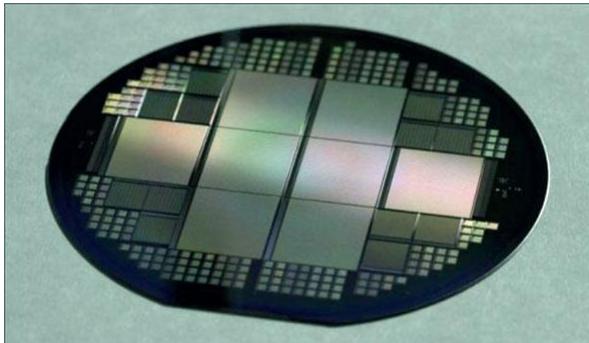
The dicing process changes the sensor

Measurement results



The dicing process changes the sensor

Measurement results



The mechanical process has changed the characteristics of the sensor.

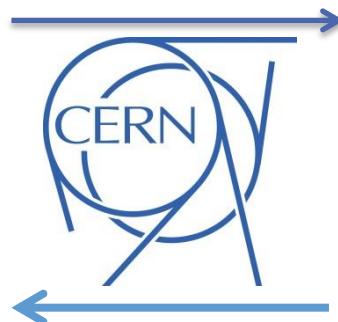
What's left to say

Review



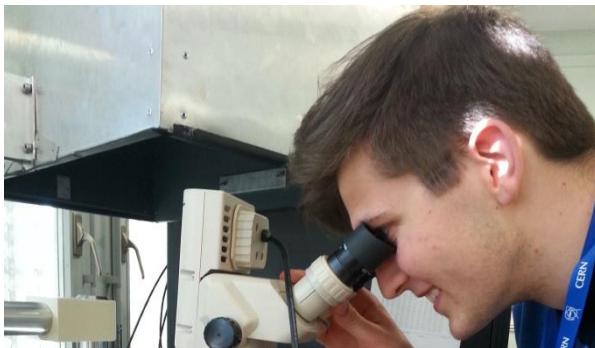
Internship:

Warm atmosphere
CV/IV measurements
→ Slightly monotone
Interest working field



Visits:

Right number
Interesting tours
Good view into CERN



What's left to say

Review

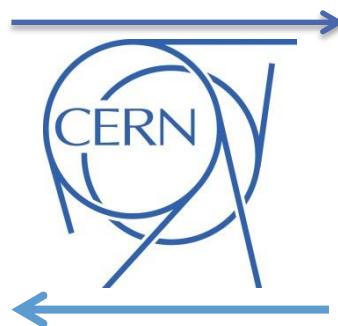


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A special thanks to the SSD-Team incl. Christian
Laura Franconi for the CV/IV measurements &
Sascha Schmeling for making everything possible